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# Introduction

Hydrogen is considered the ultimate clean energy source for solving the global energy and environmental issues. There are several ways of producing hydrogen, such as from fossil fuels, natural gas by steam reforming,<sup>1-3</sup> electrolysis of water,<sup>4</sup> reforming of biomass,<sup>5</sup> and photocatalytic water-splitting.<sup>6-8</sup> Producing hydrogen from water using natural energy, such as sunlight, is considered one of the most promising technologies for solving these problems. Semiconductors with a  $d^{10}$  electron configuration have attracted considerable attention for superior photocatalytic activities, mainly due to their conduction bands being formed by hybridized sp orbits with a large dispersion, which makes them able to generate photoexcited electrons with large mobility.<sup>9-11</sup> As a representative of such  $d^{10}$  materials, gallium oxide  $(Ga<sub>2</sub>O<sub>3</sub>)$  exhibits high activity in water-splitting and in the degradation of organic pollutants. Among the five polymorphs of gallium oxide,<sup>12</sup> the  $\beta$  phase with a monoclinic structure was reported to be commonly formed under ordinary conditions. This material has drawn much attention for its potential application in optoelectronic devices, gas sensors, spintronic devices, etc.<sup>13-18</sup> In addition, several theoretical

Yaqiang Ma,<sup>a</sup> Xu Zhao,<sup>\*a</sup> Mengmeng Niu,<sup>a</sup> Wei Li,<sup>a</sup> Xiaolong Wang,<sup>a</sup> Caiyun Zhai,<sup>a</sup> Tianxing Wang,<sup>a</sup> Yanan Tang<sup>b</sup> and Xiangi Dai<sup>\*ab</sup>

The  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> (100) surface, with or without defects, as a robust photocatalyst for water decomposition was studied on the basis of density functional theory (DFT). The surface defects considered, herein, were oxygen vacancies and doping with higher chalcogens, such as S, Se and Te. Narrowed bandgaps of the defective surfaces, leading to a high utilization of solar energy with respect to pure  $Ga_2O_3$ , were observed. By optimizing the geometrical structures of the initial molecular adsorption states (IS), the transition states (TS) and the final dissociative adsorption states (FS), the reaction activation energy and the adsorption energy of each species in the reaction pathway were obtained. Water acts as a Lewis base and provides electrons to the surfaces. The presence of water on the surfaces more likely preferred the molecular modes. The reaction results demonstrate that the surface is robust for water decomposition, where the defects, both vacancies and doping with high chalcogens, have no evident influence on the reaction parameters. The reaction pathway can be improved by vacancies or Se doping. These findings for water decomposition on  $Ga_2O_3$  (100) surfaces can be used in synthesis of photocatalysts and for understanding the interactions across the reaction pathway. PAPER<br>
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simulations have been conducted to explore its structural,<sup>19,20</sup> electronic, $21$  and optical properties. $22$ 

Recently,  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> has also been particularly noted because of its high photocatalytic activity for the water-splitting reaction.<sup>23</sup> The most stable low index surface of  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> is the (100)-B type, as has been proven by theoretical calculations and experiments.<sup>20,24</sup> The absorption behaviors of materials such as  $CO_2$ <sup>25</sup>  $CH_4$ <sup>26</sup>  $H_2$ <sup>27-29</sup> formate,<sup>2</sup> and  $CH_3OH$ <sup>30</sup> on  $Ga_2O_3$  have been investigated using DFT methods, with most of these simulations based on the (100) termination surface. However, the large bandgap of  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> (about 4.8 eV) leads to a low utilization of the solar spectrum because the material is only active in the ultraviolet region. Moreover, vacancies and doping on non-metal atoms of the catalysts are feasible considerations to improve the photo-adsorption properties by influencing the electronic structure of the photocatalysts. It was found that N doping can lead to a p-type electrical conductivity<sup>32</sup> and enable tunable light emission.<sup>33</sup> The study also showed that the nonmetal doping of  $Ga<sub>2</sub>O<sub>3</sub>$  could provide an optical bandgap in the visible region.<sup>31</sup>

In the published literature about photocatalytic watersplitting, the interactions between water and the surfaces of catalysts have been a very important subject.<sup>14,34-36</sup> Considering photocatalysts based on  $Ga<sub>2</sub>O<sub>3</sub>$  (100) surfaces, several researchers have paid great attentions to their catalytic efficiency and optical properties through carrying out experiments involving the surfaces.<sup>37-40</sup> Water adsorption on low index  $\alpha$ - $Ga<sub>2</sub>O<sub>3</sub>$  surfaces, with high activation but low stability, was



<sup>&</sup>lt;sup>a</sup>College of Physics and Electronic Engineering, Henan Normal University, Xinxiang 453007, China. E-mail: zhaoxu@htu.cn; xqdai@htu.cn

b Department of Physics, Zhengzhou Normal University, Zhengzhou, Henan 450044, China

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Monoclinic Ga<sub>2</sub>O<sub>3</sub> (100) surface as a robust photocatalyst for water-splitting†

proven by theoretical simulations.<sup>41</sup> Moreover, for the most stable phase of  $\beta$ -Ga<sub>2</sub>O<sub>3</sub>, the favorable reaction path for watersplitting on a perfect surface and on a  $NiO<sub>x</sub>$ -cluster-modified surface were studied, and it was shown that the  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> (100) surface after loading  $NiO_x$  had a significant enhancement of activity for generating oxygen.<sup>42,43</sup> To the best of our knowledge, there is no report in literature on the impact of the watersplitting reaction with chalcogenide doping. Because the partial decomposition ( $H_2O \rightarrow H + OH$ ) of water is easier than the complete decomposition  $(H_2O \rightarrow 2H + O)$ , the surface hydroxyl radical is more critical for photocatalysis. Hence, in this study, we only considered the partial decomposition of water. Paper<br>
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In this study, we performed DFT calculations to investigate the water adsorption and decomposition on  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> (100) surfaces. Introducing a non-metal vacancy and chalcogen doping were considered to ameliorate the solar utilization and reaction path. The main purpose of this study was to comprehend the interactions between water and the photocatalytic surfaces in order to supply theoretical guidance to efficiently synthesize  $Ga<sub>2</sub>O<sub>3</sub>$  catalysts.

### Computational details and models

All the DFT calculations were performed using the Vienna Abinitio Simulation Package (VASP) code.<sup>44,45</sup> The projectoraugmented wave (PAW) method was applied to describe the electron–ion interactions.<sup>46,47</sup> The exchange–correlation potentials were described through the Predew–Burke–Ernzerhof (PBE) function within the generalized gradient approximation (GGA) formalism.<sup>46</sup> A plane wave basis set with a cutoff energy of 420 eV and a 5  $\times$  3  $\times$  1 *k*-points grid, determined by the Monkhorst-Pack method<sup>48</sup> for all the surfaces were found to give good converged results. The atomic structures were relaxed using the conjugate gradient algorithm as implemented in the VASP code until the forces on all the unconstrained atoms were smaller than 0.01 eV  $\AA^{-1}$ . Dipole correction calculations were performed to compensate for the long-range dipolar interactions with periodic images across the vacuum region. Transition states along the reaction pathway were tested using the CI-NEB (climbing image nudged elastic band) method<sup>49,50</sup> and the number of images inserted between the IS and FS were approximately equal to three times the number obtained by the running script  $(dist.pl)$  in the VTST script packages.<sup>51</sup>

The formation energies of X-doped defect surfaces,  $\Delta E_{\rm f}^{\rm X}$ , and the adsorption energies of  $H_2O$  on all the substrate surfaces,  $\Delta E^{\rm H_2O}_{\rm ads.}$  , are defined as follows:

$$
\Delta E_{\rm f}^{\rm X} = E_{\rm X\text{-doped}}^{\rm Total} - E_{\rm perfect}^{\rm Total} + \mu_{\rm O} - \mu_{\rm X},
$$

$$
\Delta E_{\text{ads.}}^{\text{H}_2\text{O}} = E_{\text{H}_2\text{O}+\text{Sub}}^{\text{Total}} - E_{\text{Sub}}^{\text{Total}} - \mu_{\text{H}_2\text{O}},
$$

where  $E_{\text{X-doped}}^{\text{Total}}$ ,  $E_{\text{Defect}}^{\text{Total}}$ ,  $E_{\text{H}_2\text{O+Sub}}^{\text{Total}}$  and  $E_{\text{Sub}}^{\text{Total}}$  represent the total energy of the surfaces with and without dopants, and with and without H<sub>2</sub>O absorption, respectively. The quantity  $\mu_X$  (X = O, S, Se, Te and  $H_2O$ ) is the chemical potential of the X atom or molecule obtained from the energy calculation for the X atom or molecule in a cubic cell with a side length of  $15 \text{ Å}$ . According to the above definitions, positive values of the absorption energy correspond to an endothermic process, whereas negative values indicate that the adsorption is thermodynamically favorable.

The average difference in electron density for water adsorption on the  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> (100) surfaces along the z direction is defined as follows:

$$
\Delta \rho = \int \rho_{\text{water+Surf.}}(x, y, z) dxdy - \int \rho_{\text{Surf.}}(x, y, z) dxdy
$$

$$
- \int \rho_{\text{water}}(x, y, z) dxdy,
$$

where  $\rho_{\text{water+Surf}}(x, y, z)$ ,  $\rho_{\text{Surf}}(x, y, z)$  and  $\rho_{\text{water}}(x, y, z)$  are the charge density at the  $(x, y, z)$  points in the lattice of the water adsorbed surface, the surface and the water molecule, and the decomposition products lattice, respectively. Consequently, positive values indicate an increase in charge density at this position, whereas negative values indicate a decrease in charge density.

The unit cell of  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> contains 8 Ga and 12 O atoms with a base centered monoclinic structure (Fig. 1(a)). Gallium atoms can be divided into two categories:  $Ga<sub>1</sub>$ , which is tetrahedrally coordinated, and  $Ga<sub>2</sub>$ , which has six O neighbors in a distorted octahedral arrangement. Furthermore, the oxygen atoms can be distinguished by  $O_1$ ,  $O_2$  and  $O_3$ .  $O_1$ , shared by one octahedron and two tetrahedron gallium atoms, is not on the same plane of



Fig. 1 The models of the  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> unit cell and the perfect (100) surface: (a) the bulk  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> unit cell crystal, (b) a cross view of the  $\beta$ - $Ga<sub>2</sub>O<sub>3</sub>$  (100) surface, (c) top view of the (100) surface. In all of this text, the color of the gallium (Ga) oxygen (O), sulfur (S), selenium (Se), tellurium (Te) and hydrogen (H) atoms are identified by gray, red, yellow, dark goldenrod, dark orange, and white, respectively.

a Ga triangle, whereas  $O_2$ , shared by two octahedrons and one tetrahedron, lies in the plane of a Ga triangle. In addition,  $O_3$ has four Ga neighbors tetrahedrally arranged. A vacuum layer of 15 Å between successive slabs along the  $[001]$  direction was used to separate the two heterostructures in order to avoid spurious interactions due to the nonlocal nature of the correlation energy.<sup>52</sup> The perfect (100) surface is shown in Fig. 1(b) and (c). On the pure surface, 4-fold-coordinated gallium  $(Ga_1)$ , 5-foldcoordinated gallium  $(Ga_2)$ , 3-fold-coordinated oxygen  $(O_1)$  and 3-fold-coordinated  $(O_3)$  were exposed, among which  $Ga_2$  and  $O_3$ were unsaturated. In total, hundred and twenty atoms with twenty-four molecular units in the slabs were distributed in six atomic layers. The bottom two layers were fixed in their bulk positions in all the calculations, whereas the top four layers, together with the adsorbents, were allowed to relax.

### Results and discussion

#### 1. Electronic properties of the  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> (100) surface with an oxygen vacancy or doped with higher chalcogens (S, Se and Te)

 $\beta$ -Ga<sub>2</sub>O<sub>3</sub> has a C2/m symmetry with four formula units per crystallographic cell, and is characterized by four lattice parameters, namely  $a$ ,  $b$ ,  $c$  and  $\beta$ . The optimized lattice parameters for  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> are  $a = 12.26$  Å,  $b = 3.05$  Å,  $c = 5.82$  Å, and  $\beta = 103.65^{\circ}$ , and agree well with experimental values and other DFT values.<sup>23,31,40</sup> The density of states (DOS) of the bulk  $\beta$ - $Ga<sub>2</sub>O<sub>3</sub>$ , shown in Fig. 3(a), was calculated to obtain the structure of the electronic states for the material. The valance band (VB) was mainly contributed by the oxygen 2p orbits, where the  $O<sub>3</sub>$ component was the smallest and  $O<sub>2</sub>$  the largest. In the conductive band (CB), the gallium s character was the main component and the 3s orbits of the  $Ga<sub>2</sub>$  atoms were slightly larger than those of the Ga<sub>1</sub>. The energy bandgap  $(E_b)$  in this calculation was 2.29 eV (less than the experimental value, which

is within 4.6–4.8 eV), which can be explained by the GGA-PBE pseudopotential chosen in the DFT calculations, which underestimates the bandgap by 2–3 eV, and overestimates the lattice parameters. The agreement with the other DFT values was excellent.

Four types of positions for both vacancies and doping were considered in the initial configurations, which were categorized by the atoms on the surfaces. The most stable structures of the defect surfaces are shown in Fig. 2, which are all located at  $O<sub>3</sub>$ sites, not only for vacancies but also for the doping with S, Se and Te. The calculated formation energy of the  $V_{O<sub>3</sub>}$  surface is 2.909 eV, which is higher than those reported earlier.<sup>14,15</sup> This may be due to the different choice of the chemical potential of the oxygen atoms in this study compared to the other reports in the literature. A single value of atomic energy was used in this study, which was half the energy of molecular oxygen described in the previous literature. For S-, Se-, and Te-doped surfaces, the formation energies are listed in Table 1. The S-doped surface had the lowest energy and the Te-doped surface had the highest energy because the large radius of the Te atom hinders the doping. There were only a few areas of damage in the construction of the surfaces, which demonstrated that the defects were reasonable. For  $V_{O_3}$  (Fig. 2(a and b)), the most distorted part after optimization was around the  $Ga<sub>1</sub>$  site. Because of the relatively large atomic radius of S, Se and Te compared to O (Te 1.44 Å, Se 1.15 Å, S 1.01 Å, O 0.60 Å), the Ga-X  $(X = S, Se$  and Te) bond lengths were elongated, leading to the dopants being above the surfaces by 0.75 Å, 0.97 Å and 1.15 Å, respectively. BSC Advances Articles. On hand by two octahedrons and one is within 4.6-4.8 eV<sub>i</sub>, which can be positive the mathematic on the president in the DY creation of the DY creation of the Creation of the Creation of the Creatio

The DOS of all the surfaces are shown in Fig. 3. For the perfect (100) surface, the total DOS for the structure was almost the same as for the DOS of the bulk; however, the bandgap was slightly smaller than that for the unit cell, as shown in Fig. 3(b). An extra peak appeared in the DOS for  $V_{O<sub>2</sub>}$  (seen in Fig. 3(c))



Fig. 2  $\:$  Structures of the defective surfaces. (a) Across view of the ß-Ga<sub>2</sub>O<sub>3</sub> (100) surface with O<sub>3</sub> vacancy (V $_{\rm O_3}$ ), (b) top view of V $_{\rm O_3}$ , (c) across view of S-doped β-Ga<sub>2</sub>O<sub>3</sub> (100) (S-doped) surface, (d) top view of S-doped surface, (e) across view of Se-doped β-Ga<sub>2</sub>O<sub>3</sub> (100) (Se-doped) surface, (f) top view of Se-doped surface, (g) across view of Te-doped  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> (100) (Te-doped) surface, (h) top view of Te-doped surface.

Table 1 Data of the formation energy (in eV), charge transfer (in |e|) and heights (in Å) of the dopants compared to the perfect surface

	$\Delta E_{\rm f}^{\rm X}$	$e_{\text{Ga}_{1}}$	$e_{\text{Ga}_2}$	$e_{\rm O}$	$e_{\mathrm{O}_3}$	$e_{\text{chalcogen}}$	$\Delta e_{\text{Surf.}}$	$\Delta h$
Bulk		$-1.837$	$-1.884$	1.240	1.243			
Perfect		$-1.810$	$-1.859$	1.207	1.213		$-7.497$	
$V_{O_3}$	2.909	$-1.046$	$-1.644$	1.194	1.201		$-7.429$	
S-doped	3.307	$-1.651$	$-1.739$	1.221	1.217	0.797	$-7.514$	0.745
Se-doped	4.005	$-1.594$	$-1.697$	1.221	1.217	0.630	$-7.522$	0.968
Te-doped	4.849	$-1.515$	$-1.619$	1.222	1.220	0.390	$-7.553$	1.150



Fig. 3 DOS of the unit cell and (100) surfaces. (a) Bulk, (b) pure (100) surface, (c) V<sub>O<sub>3</sub></sub> surface, (d) LDOS of Ga<sub>1</sub> atom, which is the nearest of vacancy on the V<sub>O<sub>3</sub></sub> surface, (e) S-doped surface, (f) LDOS of S in the S-doped surface, (g) Se-doped surface, (h) LDOS of Se in the Se-doped surface, (i) Te-doped surface, (j) LDOS of Te in the Te-doped surface

between CBM and VBM, which is called the "impurity state". The peak comes from the three dangling bonds left behind after O3 leaves. The impurity state is mainly contributed by the 4s and 4p orbits of Ga near the defect site, with the  $Ga<sub>1</sub>$  atom having the greatest contribution, as indicated in Fig. 3(d). The band gaps for the S-doped surface, Se-doped surface and Te-doped surface were 1.84 eV, 1.66 eV and 1.49 eV, respectively. The VBM edges of the doped systems were shifted upwards, and were mainly composed of S 3p, Se 4p and Te 5p orbits, which are shown in Fig. 3(d), (f) and (j), whereas the CBM remained almost unchanged. This was due to the higher energy of S 3p, Se 4p and Te 5p compared to the O 2p orbits, in which this trend is consistent with the other results.<sup>31</sup> The narrowing band gap indicates that the utilization ratio of solar energy for watersplitting by this type of photocatalysts, if they could be used, would be significantly improved.

Charge transfer was calculated by Bader charge analysis<sup>53-55</sup> to further understand the distribution of surface atoms, which are labeled in Table 1. Although the absolute values of the Bader charges are not the exact values for the electrons transferred,

the relative values can clearly show us the distribution of charges. In this article, negative values indicate electron loss, whereas positive values represent a gain in electrons.  $Ga<sub>1</sub>$ ,  $Ga<sub>2</sub>$ ,  $O<sub>1</sub>$ , and  $O<sub>3</sub>$ , respectively, denote the atom types defined in the previous paragraph. However, for the deficient surfaces, they represent the atom's proximity to the defects, because the symmetries are destroyed by the defects.

The  $\Delta e_{\text{Surf.}}$  in Table 1 is defined as the sum of charge transfers for all the atoms on the surfaces. For all the surfaces, the  $\Delta e_{\text{surf}}$  had negative values, which indicates that the surfaces had lost charge and could easily gain electrons. Surfaces with a charge loss or gain will more easily absorb small molecules.<sup>47</sup> Comparing all the surfaces together, the  $\Delta e_{\text{Surf.}}$  for the V<sub>O3</sub> surface was the lowest (7.429 |e|), whereas the Te-doped surface lost the most charge (7.553 |e|), indicating that the Te-doped surface had the highest adsorption ability.

The charge transfer of  $Ga_1$  and  $Ga_2$  to the  $V_{O_2}$  surface was changed the most because of the bond breaking. Compared with the pure surface, the charge transfer of  $Ga<sub>1</sub>$  and  $Ga<sub>2</sub>$  was reduced by 0.791 |e| and 0.242 |e|, respectively, leading to the

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least surface charge loss, with a value of 7.429|e|. When S, Se or Te was doped, the transferred charges of S, Se and Te of the defective surface were all smaller than that for  $O_3$  (0.797–1.213) |e|, 0.630–1.213 |e|, and 0.390–1.213 |e|, respectively), which manifested that the S, Se and Te atoms got fewer electrons than O. Therefore, the strengths of the Lewis bases for S, Se and Te are weaker than that for O and this will lower the bond strength for adsorbing the H atoms from the water molecules.

#### 2. Water adsorption and decomposition on  $Ga<sub>2</sub>O<sub>3</sub>$  (100) surfaces

For all the surfaces, the Bader charges of Ga atoms had negative values, indicating that these atoms all carried positive charges, which indicates that these sites would become strong Lewis acids and could absorb the  $\rm H_2O$  molecules through the  $\rm O_w$ .<sup>56</sup> On the contrary, surface oxygen atoms showing positive values, which carried negative charges, would be strong Lewis bases for adsorbing the H atoms of water molecules.  $Ga<sub>2</sub>$  lost more electrons than Ga<sub>1</sub>, whereas  $O_3$  gained more electrons than  $O_1$ , which can be seen in Table 1, with these trends also being consistent with the other results.<sup>20</sup>

For the water molecule, the charge transfer of  $O_w$ , as shown in Table 2, was 1.142  $|e|$  and for the H atom, it was  $-0.571$   $|e|$ . After the combination of two hydrogen atoms, which respectively lost one electron, the  $O_w$  formed two pairs of bonding electrons by combination with two single 2p orbits of the O atoms. The pairs of electrons in the 2s and 2p orbits of the  $O_w$ are called lone pair electrons, which can act as Lewis bases by their loss in a reaction. On the contrary, the two H atoms will act as Lewis acids due to the bonding electron pairs tending toward the O atom, forming empty orbits. Adsorption sites between the  $H<sub>2</sub>O$  molecule with the  $Ga<sub>2</sub>O<sub>3</sub>$  (100) surfaces were considered with Lewis acids or bases of both the H2O molecules and the structures of the surfaces. Seven initial fundamental models are shown in Fig. 4. The water molecule acts as a Lewis base, and the  $O_w$ -Ga bond is the main driving force in water adsorption,

2.1 Water adsorption and decomposition on a perfect (100) surface. As many as 24 types of initial adsorption structures were modeled according to Fig. 4 and the superficial atomic types. The most stable structure after being fully relaxed is shown in Fig. 5(a) for IS, which was optimized from the structure shown in Fig. 4(d). The  $O_w$  atom lies on top of the  $Ga_2$  atom and the two H atoms move toward the  $O<sub>3</sub>$ . That is accounted for by the Ga<sub>2</sub> sites having a stronger acidity compared to Ga<sub>1</sub>. The lengths of  $O_w-Ga_2$  and  $O_w-H$  and the angle of H– $O_w-H$  ( $\angle$ HOH) are given in Table 2. The plane of the water molecule is approximately parallel to the surface, with an angle  $(\angle W-S)$  of  $6.704^\circ$ . There are good agreements with the other DFT values for water adsorption on the  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> (100) surface.<sup>43</sup> The adsorption energy of water on the perfect surface was  $-0.480$  eV. Compared with the water molecule, the bond length of  $O_w$ –H is elongated about 0.1 Å and the angle of H–O<sub>w</sub>–H is increased by 0.2°. This structural distortion of the adsorbed  $H_2O$  compared with its gas-phase structure indicates that the adsorbed  $H_2O$  is activated. **SSC Arbanes**<br>
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According to the Lewis acid–base theory, the OH radical will be adsorbed onto the top site of Ga atoms, becoming a surfaceadsorbed hydroxyl radical, and another product H atom is absorbed onto the O atoms of the surface.<sup>46</sup> According to the most stable adsorption structure of adsorption, the possible original structures for the decomposition states could be structured with the OH vertically put on top of  $Ga_{ads}$ ,  $O_w$  next to  $Ga<sub>2</sub>$  and the H atom from the water placed on top of  $O<sub>1</sub>$  or  $O<sub>3</sub>$ near the  $Ga<sub>2</sub>$  atom. The decomposition structure after being fully relaxed is shown in Fig. 5(a) for FS, with an adsorption energy of  $-0.271$  eV. The O<sub>w</sub> atom lies on top of the Ga<sub>2</sub> atom and the two H atoms move toward the  $O<sub>3</sub>$ . The angle between

Table 2 Data of the adsorption energy (in eV), the structures (lengths in Å and angles in deg.) and charge transfer (in |e|) for the water molecule and its adsorption and decomposition on perfect and defective surfaces





Fig. 4 All the possible models of a water molecule adsorbed on the Ga<sub>2</sub>O<sub>3</sub> (100) surfaces. (a) Ga-O bridge site, (b) O-O bridge site, (c) Ga-Ga bridge site, (d–f) Ga top sites, (g) O top site.



Fig. 5 (a) Adsorption configurations and decomposition reaction pathway for water on the perfect Ga<sub>2</sub>O<sub>3</sub> (100) surface. (b) Average difference in electron density for water adsorption on the perfect Ga<sub>2</sub>O<sub>3</sub> (100) surface along the z direction. The horizontal dashed line with the blue color in (b) denotes the position of the surface.

OH + H fragment and the surface is  $33.006^{\circ}$ . The detailed structural parameters of the water adsorption and decomposition on the intact surfaces are shown in Table 2.

The configuration of the transition state between these two states was also calculated, and is shown in Fig. 5(a) for TS. The

structure of TS is similar to the dissociative state, i.e., it belongs to the "late barrier" and its adsorption energy is  $-0.266$  eV. The decomposition pathway of water on the perfect surface is shown in Fig. 5. By the abovementioned results, the decomposition reaction on the perfect  $Ga<sub>2</sub>O<sub>3</sub>$  (100) surface is shown to be an RSC Advances **RSC Advances** Paper **RSC Advances** Paper **Paper Paper Paper Paper** Paper Pap

endothermic reaction with a reaction energy of 0.209 eV. Water molecules need an energy of 0.214 eV from the initial molecular state to accomplish the decomposition reaction, but the reverse reaction barrier is very small, with a value of 0.005 eV. These data demonstrate that the molecular adsorption state is the favorable state for water on the perfect  $Ga_2O_3(100)$  surface. That is to say, the water is mainly in the form of a molecule and it is very difficult to dissociate it on the perfect surface.

The Ga atoms below the  $O_w$  atoms were defined as "Ga<sub>ads.</sub>", whereas the O atom on the surfaces connected to the decomposition products of H atoms were called " $O_{ads}$ ". H<sub>1</sub> is defined as the H atom which decomposes to form  $H<sub>2</sub>O$  because of its inequitable position.

The results of the charge transfers are summarized in Table 2. Charge transfers for free water molecules are also given in Table 2 as a reference. In both molecular adsorption and decomposition on the surface, the electrons transfer from the adsorption water to the surface, indicating that  $H_2O$  acts as a Lewis base and provides electrons to the surface.

The average difference in charge density for water adsorption on the perfect  $Ga<sub>2</sub>O<sub>3</sub>$  (100) surface along the z direction, as shown in Fig. 5(b), was calculated to further understand the charge redistribution in this process. For water molecule adsorption, the average charge density between the water and the surface is increased, indicating that a covalent bond is formed. However, the average charge density of the region between the water decomposition products is mainly negative and the electrons significantly concentrate in the position of the  $O_w$  atom, which indicates that there is an ionic bonding interaction between the surface and the main decomposition product of OH.

2.2 Water adsorption and decomposition on the oxygen vacancy  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> (100) surface. The symmetries of the surfaces

are destroyed by the existence of defects. Up to 32 types of initial adsorption structures were modeled for the  $V_{O<sub>2</sub>}$  surface. The initial adsorption sites considered, herein, are described in Fig. S1.† We also take into account the adsorption energies for when water adsorbs upon or near the defect sites in Table S1.† The stable structure, with an adsorption energy of  $-0.459$  eV, is shown in Fig. 6 (IS), which also was optimized from the structure shown in Fig. 4(d). The  $O_w$  of the H<sub>2</sub>O molecule lies on top of the Ga<sub>2</sub> atoms and the two H are placed toward the  $O_3$  atoms. The stable site chosen by water is neither the vacancy nor the farthest position from the vacancy, which is similar to the perfect surfaces. The plane of the water molecule has an angle of  $11.244^{\circ}$  to the surface. The other structural parameters are shown in Table 2. Compared with the water molecule, the bond length of  $O_w$ –H is elongated by about 0.1 Å and the angle of H–  $O_w$ –H is increased by 0.02 $^{\circ}$ , indicating an active water molecule. BSC Advances Common Computer articles. The common Com

The dissociative adsorption state is shown in Fig. 6(a) for FS, in which one of the decomposition products of OH come to the bridge between Ga<sub>ads.</sub> and  $O_{ads}$  with H moving toward  $O_{ads}$ , and another product is an H atom adsorbed onto the  $O_3$  on the surface to form another surface-terminated OH radical. The adsorption energy of the dissociative state was  $-0.032$  eV and the angle between the plane of the  $OH + H$  fragment and the surface was 32.085°.

The transition state, shown in Fig. 6 (TS), is similar to the decomposition state and belongs to the "later transition state", with an adsorption energy of  $-0.277$  eV. The reaction barrier for the water decomposition reaction was 0.182 eV, whereas its reverse reaction barrier was 0.055 eV. These results demonstrate that it is more reasonable for a water molecule to be adsorbed on the  $V_{\Omega_2}$  surface, but not in the dissociative state. The barrier for the reverse reaction in this pathway is higher than for water dissociation on the perfect surface.



Fig. 6 (a) Adsorption configurations and decomposition reaction pathway of water on the V<sub>O<sub>3</sub> surface. (b) Average difference in electron density</sub> for water adsorption on the  $V_{O_3}$  surface along the z direction.

In both the water molecule adsorption and decomposition on the  $V_{O<sub>2</sub>}$  surface, the electrons transfer from the adsorption water to the surface, as can be seen in Table 2, indicating that H2O acts as a Lewis base and provides electrons to the surface. Fig. 6(b) shows the average difference in electron density for water adsorption on the  $V_{\text{O}_2}$  surface along the z direction. The molecular adsorption state is similar to water adsorption on the perfect surface, with an increase in the average charge density between the water and the surface, which demonstrates that a covalent bond was formed. The average charge density of the region between the water decomposition product OH and the surface, as shown in Fig. 6(b), has a negative value, but a small positive range (close to 1.25 Å), and the electrons are significantly concentrated around the position of the  $O_w$  and upon the surface, which indicates that the interactions between the surface and the main decomposition product of OH are ionic bonding, whereas covalent bonding only plays a very weak role. Paper<br>
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2.3 Water adsorption and decomposition on chalcogenidedoped surfaces. When water molecules adsorb on chalcogenidedoped surfaces, the most stable structures are obtained from 33 types of initial adsorption structures and these are shown in Fig. 7(a) for IS, Fig. 8(a) for IS, and Fig. 9(a) for IS, respectively. The initial adsorption sites considered here are modeled by Fig. 4 and S1.† For the S-doped surface, the  $O_w$  is almost occupied upon the  $Ga_2$  atom, which is the nearest of the S atoms, and the two H atoms move toward  $O_1$  and  $O_3$ , which optimizes the structure seen in Fig. 4(d). However, for Se- and Te-doped surfaces, the position of  $Ga_{ads}$  is the same as the  $V_{O<sub>3</sub>}$ surface, which is neither the nearest nor the furthest from the defect site, and two H atoms move toward two different directions, as shown in Fig. 8(a) for IS and Fig. 9(a) for IS. The high

adsorption height for water on the S-doped surface can be explained by the neighbors of the S atoms on the surface, which have bigger radical than O atoms and fewer electrons. Nevertheless, for Se- and Te-doped surfaces, the  $Ga_{ads}$  moves away from the dopants. The water molecule on the Te-doped surface is the most stable case among the three. The angle between the plane of the water molecular and the chalcogenide-doped surfaces were  $25.843^{\circ}$ ,  $17.755^{\circ}$ , and  $7.061^{\circ}$ . With increasing the atomic number of the dopants, the bond lengths of  $O_w$ –H are elongated and the angle of  $H-O<sub>w</sub>-H$  is increased. Therefore, surfaces doped with chalcogenides have a higher activity for water adsorption than a perfect surface.

The decomposition configurations on the chalcogenidedoped surfaces are shown in Fig. 7(a) for FS, Fig. 8(a) for FS, and Fig. 9(a) for FS. For water composed on the S-doped surface, the H<sub>1</sub> atom connects with  $O_3$  and another following, with  $O_w$ pointing to the defect site. When water is decomposed on the Se-doped surface, the  $H_1$  connects with  $O_1$  and another follows, with  $O_w$  moving toward another  $O_1$  site near  $Ga_{ads}$ , which connects with  $O_w$ . The  $O_w$  atom lies on top of the  $Ga_2$  atom and the two H atoms move toward the  $O_3$  in the case of Te doping. Other structural parameters of water decomposition on the chalcogenide-doped surfaces of  $Ga<sub>2</sub>O<sub>3</sub>$  (100) are exhibited in Table 2.

Fig. 7(a) for TS, Fig. 8(a) for TS, and Fig. 9(a) for TS show the transition states, and also the reaction pathway. All the structures of the TS are similar to the dissociative states, which also belongs to the "late barrier", and the adsorption energies for the S-, Se-, and Te-doped surfaces are  $-0.251$  eV,  $-0.268$  eV and  $-0.285$  eV, respectively. In line with increasing the atomic number of the dopants, the reaction barriers for the water



Fig. 7 (a) Adsorption configurations and decomposition reaction pathway of water on the S-doped surface. (b) Average difference in electron density for water adsorption on the S-doped surface along the z direction.



Fig. 8 (a) Adsorption configurations and decomposition reaction pathway of water on the Se-doped surface. (b) Average difference in electron density for water adsorption on the Se-doped surface along the z direction.



Fig. 9 (a) Adsorption configurations and decomposition reaction pathway of water on the Te-doped surface. (b) Average difference in electron density for water adsorption on the Te-doped surface along the z direction.

decomposition reaction respectively are 0.223 eV, 0.202 eV and 0.217 eV. However, the reverse reaction barriers are 0.004 eV, 0.041 eV, and 0.048 eV respectively, which are much smaller than the reaction barriers. Therefore, the water is also mainly in the form of a molecule and it is difficult for it to exist on the chalcogenide-doped surfaces.

The charge transfer for water molecule adsorption and decomposition (Table 2) has negative values, indicating that H2O acts as a Lewis base and provides electrons to the surfaces. The average difference in electron density for water adsorption on chalcogenide-doped  $Ga<sub>2</sub>O<sub>3</sub>$  (100) surfaces along the z direction, respectively, can be seen in Fig. 7(b), 8(b) and 9(b). In the case of molecular adsorption, the electrons are mainly gathered between the surfaces and the position of the  $O_w$  atoms, indicating that the interactions between the surfaces and the water molecules are mainly covalent bonds. The interactions between the surface and the decomposition fragments are chiefly ionic bonding, with a few covalent bonds, because the average charge density between them has mainly negative values, as was shown before.

# Conclusion

In order to clarify the interactions between water and photocatalytic surfaces, a comprehensive DFT study was implemented for water adsorption and decomposition on the  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> (100) surfaces with oxygen vacancy and by chalcogen doping. Based on the formation energy, it was easy to obtain the O vacancy and S-doped surfaces, but difficult for Se and Te doping due to their larger atomic radii. For surfaces with an oxygen vacancy and high-chalcogen doping, the bandgap reduces with respect to the perfect surface, denoting that the utilization ratio of the solar energy for water-splitting by this type of photocatalysts, if it could be used, would be signicantly improved.  $H<sub>2</sub>O$  acted as a Lewis base for both adsorption and decomposition. In all cases, the transition states all belonged to the "later transition state", whereas the adsorption energy of water molecule adsorption was lower than for the decomposition state. Therefore, the present states of water on the surfaces are more likely to favor water molecules. The reaction energies were in order  $V_{O<sub>2</sub>}$  < Se-doped < Te-doped < perfect surface < S-doped. The reverse reaction barriers decreased in the order  $\mathrm{V_{O_3}}$ , Tedoped, Se-doped, perfect and S-doped. Consequently, it was more beneficial for water-splitting when the surface had a vacancy and with Se doping. The defects, both vacancy and chalcogenide-doped, had no evident effect on the reaction parameters. Furthermore, the surface with a robust nondefective-sensitive structure could be used as an antipoisoning photocatalyst. Our study has important implications for understanding the decomposition of water on  $\beta$ -Ga<sub>2</sub>O<sub>3</sub> (100) surfaces with an oxygen vacancy or chalcogenide doping. Furthermore, it can provide theoretical guidance to efficiently synthesize  $Ga<sub>2</sub>O<sub>3</sub>$  photocatalysts. Paper<br>
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